

## Versatile and advantage of high-end coatings on cover glasses for image sensors

- High-end coatings
- Patterning
- Low Defect

Our message – one-stop-shop

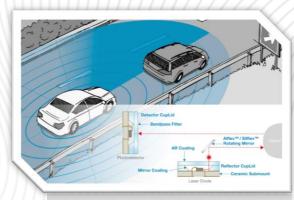
Our booth is on B11b



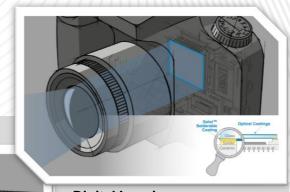
## Cover lid applications for optical sensors and cameras

**3D-Surface Measurement** 

- Automotive industry
  - ADAS (advanced driver assistance systems) and AD (autonomous driving)
  - Lane detection, traffic sign detection, pedestrian & vehicle detection
  - Enhanced visibility at nighttime or in bad weather conditions
  - Blind spot detection, parking system
  - Driver monitoring regarding drowsiness/health status
- Industrial camera market
  - Advanced maschine vision
  - Factory automation, digital measurement
  - Motion control, surveillance cameras
- Professional studio cameras and projection display
  - CCD or CMOS image sensors in digital cameras
  - LCOS micro-displays in projection applications



Scanning and solid-state LiDAR



**Digital Imaging** 



# Overview- Advanced Coatings on Cover Glasses

#### **Solderable Coatings 1**

- Hermetic package
  - Rough environment
  - Defined environment (no humidity)
  - Increased lifetime
- Electrical contact for TCOs, e.g. ITO

## AR Coatings 2

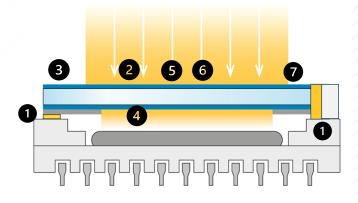
- Anhanced boardband ARC
- No waste of photons
- Signal to noise ratio

### **TopFlex™** 3

- Hydrophob
- Easy to clean

#### Low defect 4

Suits high resolution applications



#### TO **5**

- Anti static (anti dust)
- Anti fog
- Capacitive sensing
  - surface check (dirt, smutch)
  - Integrity check (e.g. eye safety)
- MIR protection
- Reflect heat rays

#### Filter 6

- High transmission
- Steep edges
- UV to IR

#### Structured Chrome and CrBlack™ **1**

- BICr / Ti / Laquer
- Defined aperture size
  - No crosstalk
  - No back reflections

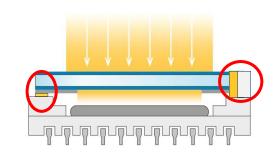


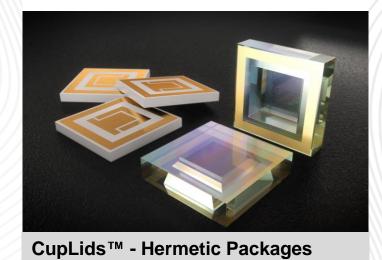
## Solderable coatings

- Fine leak hermetic solder-bonded cavity windows with ceramic submounts
- Applicable on all types of glasses and many ceramic materials
- Top side, edge and circumference coatings
- Structured forms by lithography possible
- Clean-room quality





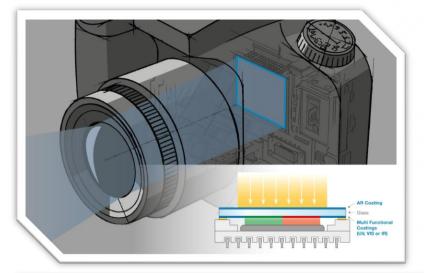




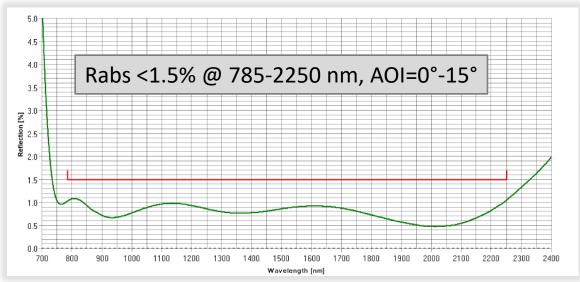
- Can be deposit as well on several other existing coatings
- Compatible with a wide variety of solders and fluxes.
- Electrical contacts like bus bars for ITO-coatings
- Stable processes and high reproducibility

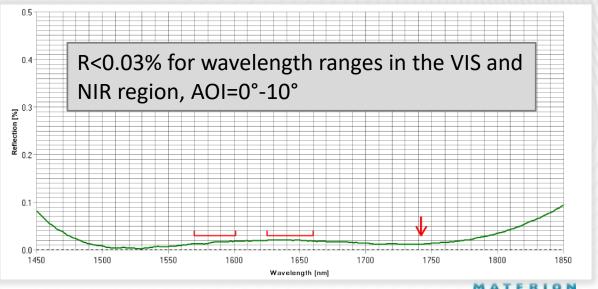


## AR Coating



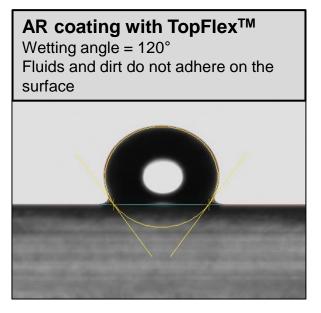
- Increased transmission
- Defect Sizes: 10µm max for piece parts
- Stable processes and high reproducibility
- From V-coatings to Advanced Broadband Coatings
- Enhanced signal-to noise ratio and contrast, eliminating ghost images
- Up to factor 10 lower reflection than with standard AR coatings

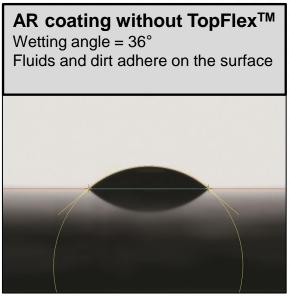


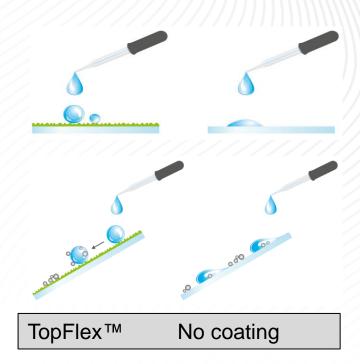


# TopFlex<sup>™</sup> – hydrophobic coating

- Easy-to-clean coating
- Solvent- and Soil-Repellent Coating
- Spectrally neutral in VIS and IR range, UV / IR Transparent
- Temperature stability up to 250°C
- Excellent environmental stability (tested according to automotive requirements)



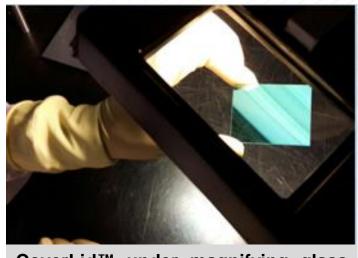




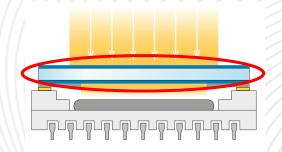


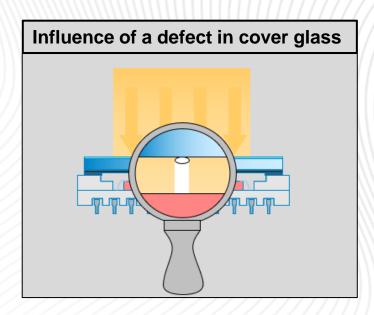
## Low Defect

- Protective Cover wherever extreme clean surfaces are required
- Reliable protection for the "digital eye" of the camera, shields the delicate image sensor, allows operation at peak performance
- No failure of pixel
- Suitable for high resolution applications
- Typical defect specification on CCD/CMOS sizes:
- AR Coating:
  - Scratch/dig 10/2 or better
  - No defects >10µm
  - NIR Blocking filter:
  - No defects > 20µm



CoverLid<sup>™</sup> under magnifying glass for checking against flaking and other contamination

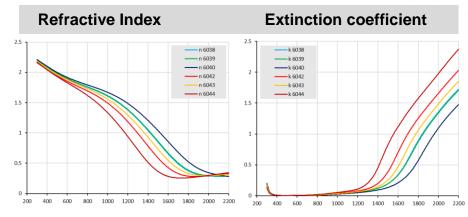






# ITO coatings

- Index Matched ITO by integration into an anti-reflective multilayer
- High conductive ITO to heat the cover glass and prevent fogging
  - LIDAR / Space application in demanding environment
- Low condutive ITO to prevent static charges
  - SMD sorting / X-Ray imaging
- Reproducible uniformity of sheet resistance of +/-20%
- Structured forms by masks and lithography possible
- Transparent in VIS and also high reflection in IR (Laser applications)

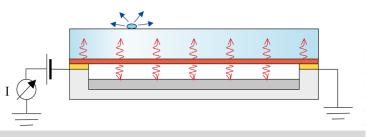






Low stress and low bow with high reproducibility

ITO with space heritage



Heater Window: Electrical current across ITO layer (red line) heats the glass and prevents from condensing moisture on surface. Yellow lines are busbars made of Gelot<sup>™</sup> for electric contacting of ITO.

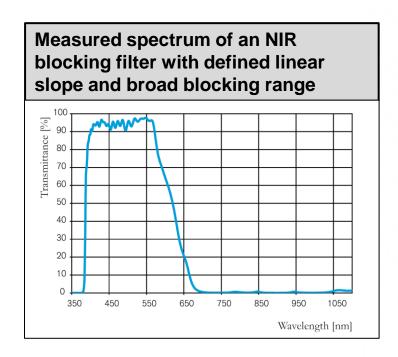


ITO with bus bars made of Gelot™



# Filter Coating

- Blocking of NIR in a broad wavelength range, NIR radiation is reflected
- Minimized angle of incidence dependence
- Edge shape depending on application → customizable
- Low Defect and Chrome Apertures possible



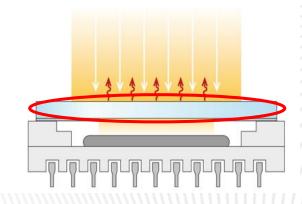
### **Typical Specification:**

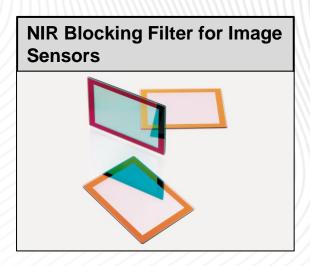
#### **Transmittance:**

Tavg > 90% @ 430-570 nm

## **Blocking:**

Tavg < 1% @ 700-1100 nm

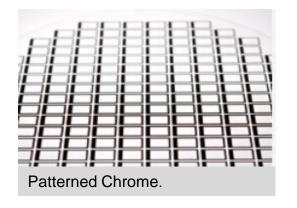


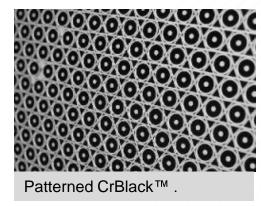


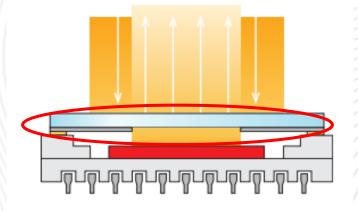


# **Patterning**

- Patterned Chrome by photolithography enables the production of highprecision structured coatings and gratings in the submicrometer range
  - Opaque low reflective, low transmittance coating
  - High resolution, low defect patterns
  - High edge performance







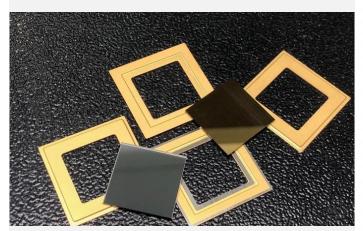
Patterned Chrome: applied as aperature defining a light beam of a projected picture..

- CrBlack<sup>™</sup> optical black coating (micro)patterned by lift-off techniques
  - High absorption and low reflection in the VIS and NIR range
  - Specifically adjusted color impression and optical density according to customer requests
  - Background noise reduction
  - Precise alignment marker

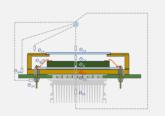


# **Optical Packaging Solutions**

#### VisiLid™

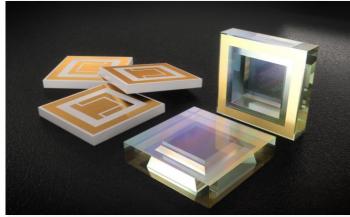


- Optical Lids and packaging materials for fine-leak hermetic packaging of Opto-Semiconductors in Hi-Rel applications
- Portfolio of thermally conductive and CTE-matched packaging materials (metals & ceramics)

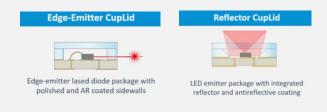


No	Materials	TC (W/m-K)	CTE (ppm/K)
1	FR-4	0.2	16
2	Al <sub>2</sub> O <sub>3</sub>	17	7
3	Si <sub>3</sub> N <sub>4</sub>	43	3.7
4	GaAs	46	5.7
5	GaN	130	3.2
6	Si	153	3.5
7	ALN	200	4.5
8	CuW	225	7
9	CuMoCu	210	8
10	Cu	393	17
11	SiC	430	4
12	Ag-Diamond	600	9
13	Diamond	1500	1.4

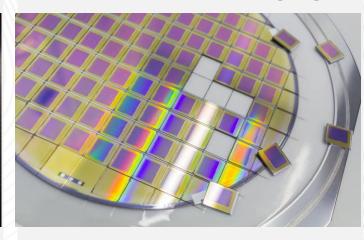
## **CupLid™**



- Surface-mount, fine-leak hermetic packages for Laser Diodes, LEDs & **Photodetectors**
- Developed for high-volume, automated chip-scale packaging of Optosemiconductors



## **Wafer-level Packaging**



- Coated & bonded wafer stacks for fineleak hermetic packaging of MEMS- and Opto-semiconductors
- Developed for cost-effective wafer-level packaging

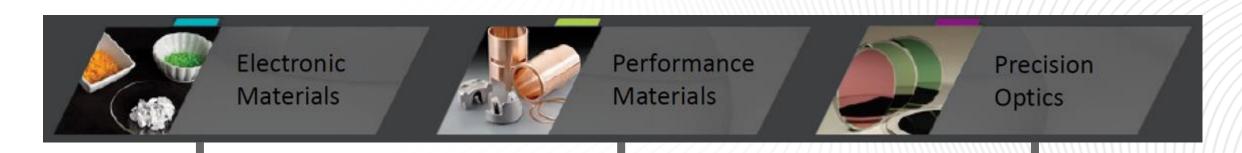




# **Materion Corporation**



# Corporate Overview – Materion's Business Units



- Precious and engineered materials for sputtering & evaporative coating
- Advanced chemicals & powders
- Microelectronic packaging materials
- Large area targets for sputtering
- Precision parts cleaning, precious metal recovery and life cycle management services

- Specialty engineered Alloy systems
- Beryllium & Composites
- Engineered Clad & Plated Metal Solutions
- Ceramics
- Advanced performance parts

- Precision filters & optical coatings
- Wafer level coatings
- Specialty thin films
- Projection display components
- Optical assemblies



## Providing high performance solutions across the spectrum

#### **LWIR** UV **VIS NIR MWIR** Water Quality Biochips Automotive LIDAR Medical Gas Sensing Thermal Imaging Industrial Automation Smart Buildings Temperature Sensings Spectroscopy Microscopy Earth Imaging Consumer AR / VR VIS 380 – 800 nm UV 200 – 400 nm NIR 900 – 1700 nm **MWIR 3 – 5 μm** LWIR 8 – 12 μm

# Core Capabilities

#### **Deposition Technology**

- Magnetron Sputtering
- Ion Beam Sputtering
- Thermal Evaporation
- Ion Assisted Deposition

#### Clean Room and Glass processing

- Photo Lithography
- Wafer Processing
- Wafer Bonding
- Dicing, Rounding, CNC, Coring

### Component Manufacturing

- Filter-Wheel Assembly
- Filter-Array Assembly
- Prism Cementing
- Beam-Combiner Assembly



## **Our History**

11946





Founding of «Gerätebau-Anstalt» by Prince Franz Josef II., Dr. Max Auwärter and Emil Georg Bührle. Main focus: Production of optical thin-film coatings



1960

**BALZERS** 

2009



Incorporation of **Optics Balzers AG** by Management-Buy-Out and local investors

1976

**OERLIKON-BÜHRLE** 

Company becomes a subsidiary of Oerlikon-Bührle Holding AG

1993

balzers

2000\_

2006 œrlikon 2010



Optics Balzers acquires mso Jena Mikroschichtoptik GmbH. Founded in 1998 by former staff of the Fraunhofer Institute



2016

2020 **OPTICS BALZERS** 

Materion acquires Optics Balzers AG



**// BALZERS OPTICS** 

1931

#### **BRUSH BERYLLIUM**

4301 PERKINS AVENUE - CLEVELAND 3, OHIO
beryllium - beryllium oxide - beryllium alloys

Capitalized with \$500, Brush Beryllium Company was incorporated on January 9, 1931 in Cleveland, Ohio



2005

Thin Film Technology, Inc. of Buellton, California. Founded in 1971, acquired by Williams

1986

Brush Acquires Williams Advanced Materials of Buffalo, NY.



2009

Williams acquires BARR Associates of Westford, MA in 2009. BARR was founded in 1971 by Ed Barr



2011

Materion acquires Shanghai based EIS Optics



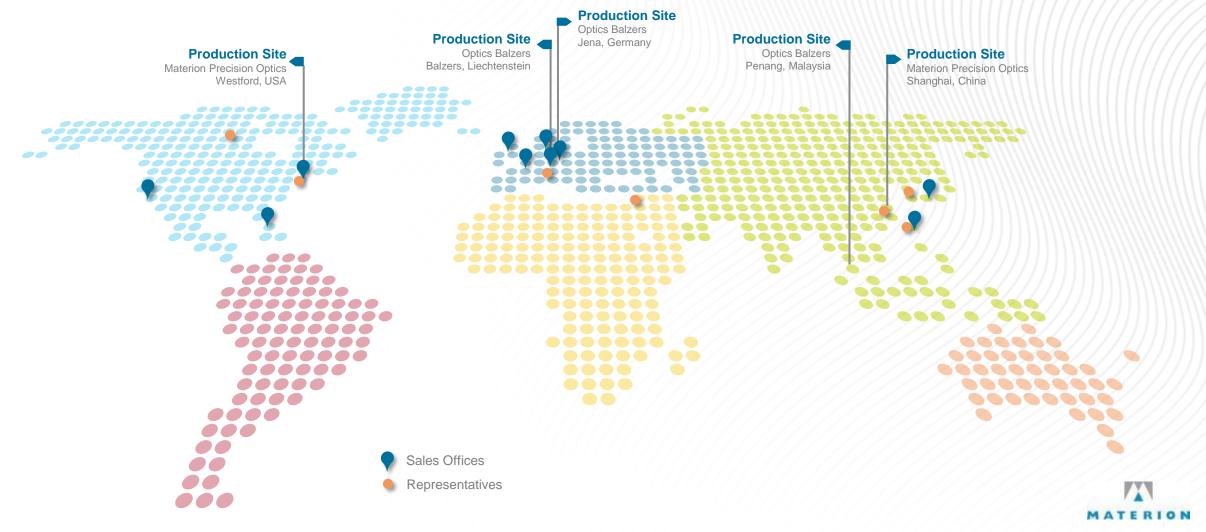
2011

Brush rebrands as Materion Corporation. Consolidates thin film coating acquisitions into Materion Precision Optics

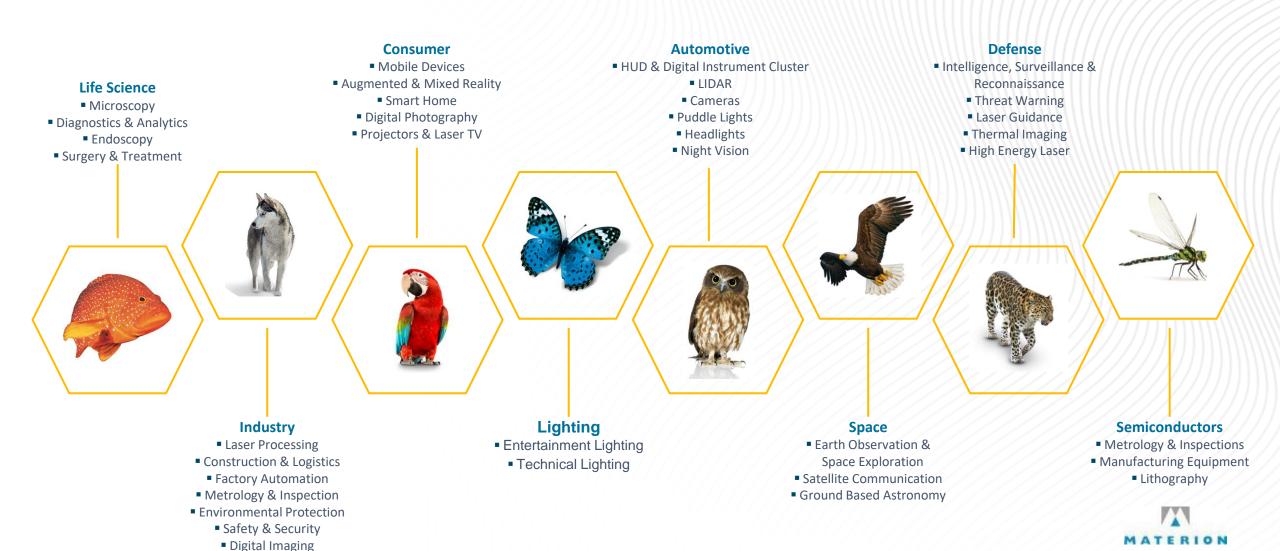




## 5 Production Sites and a Worldwide Presence



# Unlimited Applications in High-Tech Markets



■ Telecom & 5G

## **Core Capabilities**

#### **Deposition Sytems**

- Magnetron Sputtering
- Ion Beam Sputtering
- **PARMS**
- IAD
- E Beam evaporation

#### **Spectral Test**

- UV LWIR
- FWHM < 0.1nm
- Size > Ø1m
- Cryogenic < 10K

#### **Photolithography**

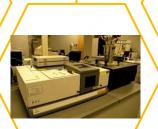
- Semiconductor grade
- Feature size < 10um
- Artwork < 1.0 um
- Precision placement +/- 1 um

#### **Assembly Lab**

- o Class 10,000 room
- Class 100 ASM station
- Temp & Humidity control Measurement accuracy
  - < 0.002mm



















- High magnification system
- Accuracy to +/- 0.002mm
- Up to Ø200 mm
- Up to 10 mm thick
- Specialty blades & procedures
- Control edge roughness < 30 A rms
- Minimize edge chipping

#### **Environmental Test**

- Humidity
- Abrasion
- Adhesion
- SALT / Fog
- Solubility
- Thermal (storage & Shock)
- Solar Flux
- Radiation

#### **Substrate Preparation**

- o Large wafers > 1M
- Automated & manual
- Individual & batch
- **Detailed inspection**



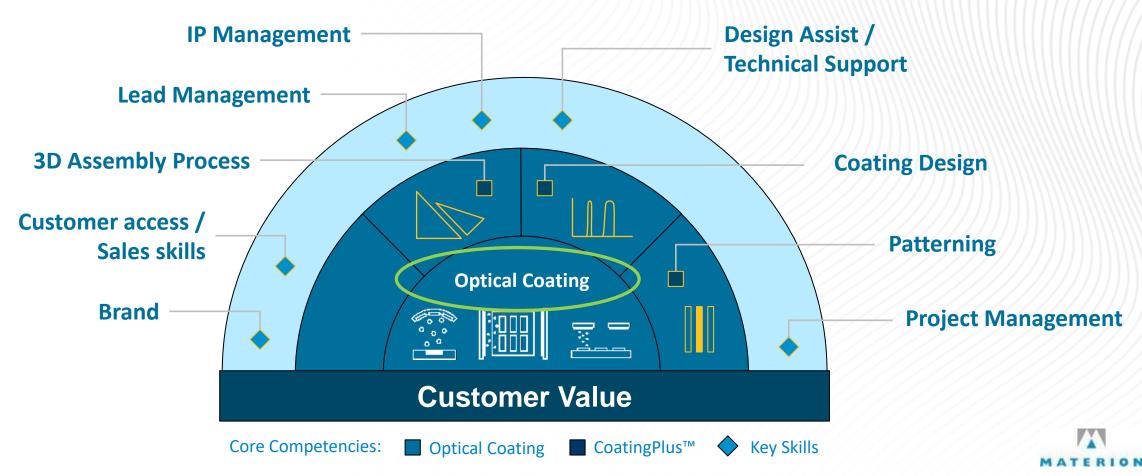
- **Substrate Preparation**
- Assembly
- Inspection
- Surface Metrology
- Deposition labs



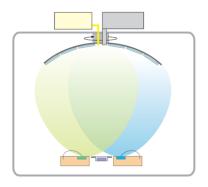


## Core Competencies and Key Skills

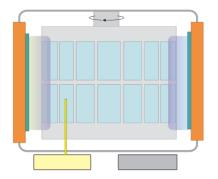
Due to the ongoing improvement and development of our core competencies and skills, we can gain a competitive advantage and maximize customer value



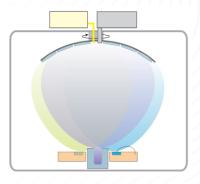
# Available coating technologies



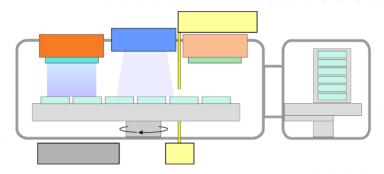
**Evaporation** (e-beam and boat sources)



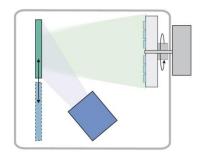
Magnetron Sputter Deposition



IAD-Evaporation (Ion Assisted Deposition)



PARMS (Plasma-Assisted Reactive Magnetron Sputter Deposition)



IBS-Deposition (Ion Beam Sputtering)

To learn more about Materion and our capabilities, please feel free to contact us:



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Materion enables what's next™



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